



Attorney's Docket No.: 05542-149004 / 784C5

3723/#  
#13 Amended  
Smt

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Manoocher Birang et al. Art Unit : 3723  
Serial No. : 09/863,118 Examiner : David Q. Nguyen  
Filed : May 22, 2001  
Title : METHOD OF FORMING A TRANSPARENT WINDOW IN A POLISHING  
PAD

Commissioner for Patents  
Washington, D.C. 20231

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JAN 30 2003

RESPONSE

TECHNOLOGY CENTER R3700

In response to the action mailed September 18, 2002, please amend the application as follows:

In the claims:

Please amend claims 17, 23, 25, 27, 31, 38 and 39 as follows:

17. (Amended) A polishing pad for a chemical mechanical polishing apparatus, comprising:

an article having a polishing surface and a surface opposite the polishing surface for attachment to a platen;

a solid substantially transparent section formed in the polishing surface; and

an aperture formed in the surface opposite the polishing surface and aligned with the transparent section.

18. The polishing pad of claim 17, wherein the article includes a first layer with the polishing surface and a second layer adjacent to the first layer.

19. The polishing pad of claim 18, wherein the transparent section extends through the first layer.

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I hereby certify under 37CFR §1.8(a) that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage on the date indicated below and is addressed to the Commissioner for Patents, Washington, D.C. 20231.

Date of Deposit JANUARY 21, 2003

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